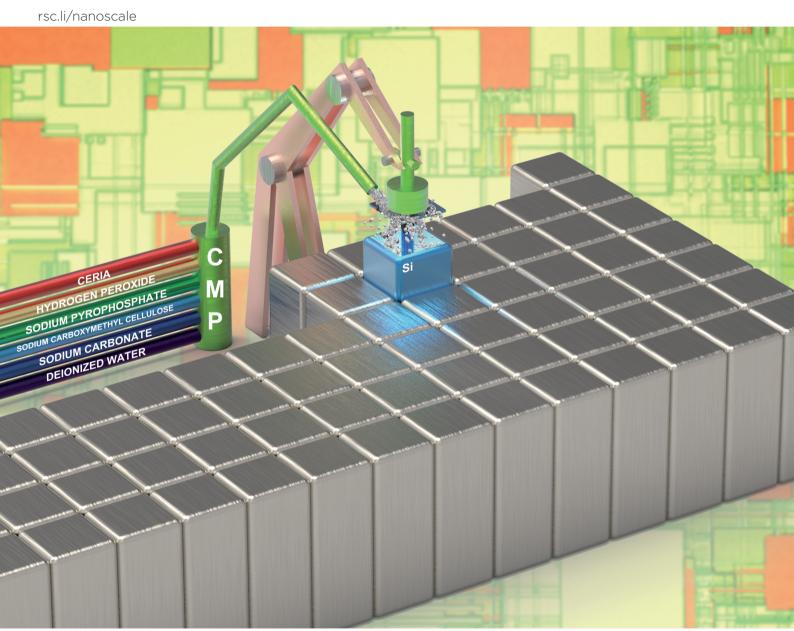
Volume 15 Number 21 7 June 2023 Pages 9231-9578

Nanoscale



ISSN 2040-3372



PAPER

Zhenyu Zhang et al.
Unprecedented atomic surface of silicon induced by environmentally friendly chemical mechanical polishing

